

NANOPHOTONICS

Hey Llama, design a metasurface for...

0.767 at 1050 nm, 0.694 at 1068 nm, 0.595 at 1087 nm, 0.433 at 1105 nm, 0.706 at 1123 nm

0.037, 0.261, 0.639, 0.6711, 0.827, 0.084, 0.867, 0.209, 0.710, 0.426, 0.643



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FOUNDING EDITOR Federico Capasso, Harvard University, USA

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E-mail: nanophotonics.editorial@degruyterbrill.com

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